

ORIENTATION DIVISION TYPE LIQUID CRYSTAL DISPLAY,
FABRICATION METHOD THEREOF AND IMAGE DISPLAY METHOD

BACKGROUND OF THE INVENTION

5 1. Field of the Invention

The present invention relates to an orientation
division type liquid crystal display device and a
fabrication method thereof and, particularly, the present
invention relates to an orientation division type liquid
10 crystal display device of an active matrix drive type,
which has a COT (Color filter on TFT) structure in which
color filters are arranged on a pixel electrode side
substrate having TFT (Thin Film Transistor) switching
elements, which is capable of widening a viewing angle of
15 pixel display. Furthermore, the present invention relates
to an image display method for use in the orientation
division type liquid crystal display device to widen a
viewing angle of the pixel display.

2. Description of the Prior Art

20 The liquid crystal display device has been utilized in
various fields as a display device for a television
receiver, personal computer and projector, etc., due to the
merits of lightweight and low power consumption
characteristics thereof. Particularly, the color liquid
25 crystal display device has become popular and the image
display mode thereof has been expanded to a monochromatic

display, multi-color display and full color display according to objects and use.

As a drive system of the color liquid crystal display, there is an active matrix drive type color liquid crystal display having a switching element such as silicon TFT provided for each of a number of display pixels for controlling a write operation of signal voltage.

With the recent improvement in fineness and coloring of a liquid crystal display device, the increase of the viewing angle of a pixel color layer region of color filters has been required in view of the image contrast and clearness of image display. In order to accommodate to such request, there have been various proposals for increasing the viewing angle by controlling orientation of liquid crystal molecules.

For example, Japanese Patent Publication of Non-Examined Application No. H7-311383 discloses a liquid crystal orientation control in which a slope portion of a transparent electrode film of ITO (Indium Tin Oxide) is provided to control the orientation of liquid crystal molecules along the slope surface.

Furthermore, an opening portion or a protruding portion is provided in a transparent electrode on the side of an opposing substrate and, in combination with the orientation control slope of the pixel electrode, the orientation of liquid crystal molecules is controlled.

In Japanese Patent Publication of Non-Examined

Application No. H8-152639, a surface of an opposing substrate on which color filters are provided correspondingly to pixel electrodes on a pixel electrode substrate is made corrugated to divide the orientation direction of liquid crystal molecules to a plurality of orientation directions along the protruding portions thereof.

Under the circumstances, it is usual in the conventional color liquid crystal display device including the above mentioned prior arts to provide pixel color layers as color filters of each of pixels on the side of an opposing substrate.

On the other hand, there is an active matrix drive type liquid crystal display device having a COT structure which includes the pixel color layers as color filters arranged on the side of a pixel electrode substrate.

By employing the COT structure in each pixel region (G, R, B) of a pixel electrode array, it is possible to concentrate the complicated fabrication process for a drain electrode, a drain wiring, a gate electrode and a gate wiring, etc., in four peripheral sides of the pixel electrode on the side of one of the substrates to thereby facilitate the fabrication and reduce the process load.

Furthermore, it is usual in one pixel region to provide a black matrix (BM) layer between adjacent pixel color layers and between corresponding pixel electrode arrays. In such COT structure, four peripheral sides of

each pixel electrode are separated from those of adjacent pixel electrodes by the BM layer while utilizing the above-mentioned merits in fabrication process. It is easy to form the BM layer thicker than a usual BM layer.

5 The conventional liquid crystal display devices described hereinbefore do not employ the COT structure. That is, color filters are arranged on the side of the opposing substrate and the slope portions, etc., are formed on the side of the opposing substrate to divide the
10 orientation of liquid crystal molecules to thereby widen the viewing angle of the pixel display.

There is no detail description of formation of slopes in Japanese Patent Publication of Non-Examined Application No. H8-152639. Assuming that such slope is formed, for
15 example, on or through a step portion provided on the side of an opposing substrate, the initial orientation of liquid crystal molecules on the side of the opposing substrate become opposite to the initial orientation of liquid crystal molecules on the side of the pixel electrode
20 substrate, so that it is impossible to evenly divide orientation of liquid crystal molecules to a plurality of directions.

In the proposal disclosed in the above-mentioned Japanese Patent Publication of Non-Examined Application No.
25 H7-311383, a transparent electrode of an opposing substrate is formed on an insulating layer to step up the transparent electrode to thereby form a slope as an orientation control

dislocation layer.

However, since the orientation control dislocation layer is usually formed by etching SiNx or SiO_2 , etc., it is not easy to form a clearly defined step portion.

5 Furthermore, it is very difficult to control the initial orientation of liquid crystal molecules to a desired angle by such gentle slope formed on such small step portion. Therefore, it is very difficult to shorten the response time by more clearly dividing the initial
10 orientation direction.

SUMMARY OF THE INVENTION

An object of the present invention is to provide, in a liquid crystal display device including a substrate having a COT structure in which pixel color layers as color
15 filters and pixel electrodes are provided on the substrate and various electrodes or electrode wiring are concentrically provided in peripheries of the pixel color layers, an orientation division type liquid crystal display device, which is superior in response time for initial
20 orientation, capable of clearly and evenly dividing the orientation direction to a plurality of directions to thereby widen a viewing angle of pixel display.

Another object of the present invention is to provide a method of fabricating such orientation division type
25 liquid crystal display device.

A further object of the present invention is to provide an image display method for widen the viewing angle

of pixel display.

As a result of studies made by the inventors of the present invention in order to solve the problems of the prior arts, it has been found that it is possible to relatively easily form a step portion in a peripheral portion of a pixel electrode during a forming process of a black matrix (BM) layer provided between adjacent pixel color layers provided correspondingly to the pixel electrode.

That is, according to the present invention, an orientation division type liquid crystal display device is featured by that a substrate opposing to an opposing substrate on which a common electrode is formed has a COT structure in which pixel color layers as color filters and pixel electrodes are provided on the substrate and a slope having a clear angle with respect to a surface of the opposing substrate is provided in a periphery of each of four sides of the pixel electrode.

The slope may be formed on at least one of a gate electrode, a gate wiring, a drain electrode, a drain wiring and a source electrode, which are provided in the peripheral portion of the pixel electrode.

Alternatively, the slope may be formed on a step portion formed by the BM layer from on one of the electrodes and one of the wiring, which has a vertical height clearly defined with respect to a plane of the pixel electrode.

According to the present invention, an orientation division type liquid crystal display device in which a similar slope is formed on a step portion formed by overlapping edge portions of adjacent pixel color layers is provided.

Liquid crystal molecules filling a space between the substrate and the opposing substrate are aligned vertically with respect to surfaces of the slopes provided in the peripheries of the four sides of the pixel electrode, so that orientation of liquid crystal molecules on the pixel electrode is divided to a plurality of directions by the slope.

According to the present invention, a method for fabricating the orientation division type liquid crystal display device is provided, which comprises the steps of arranging a pixel electrode substrate having pixel color layers as color filters and pixel electrodes thereon and slope surfaces in peripheries of four sides of each pixel electrode in an opposing relation to an opposing substrate, filling a space between the pixel electrode substrate and the opposing substrate with liquid crystal molecules so that orientation of liquid crystal molecules can be controlled by the slope surfaces.

That is, in this fabrication method, the pixel color layers corresponding to the pixel electrode are formed on an insulating layer such as an insulating film or a passivation film on the pixel electrode substrate.

Then, the step portions are formed by the BM layer having thickness larger than a thickness of the pixel color layers and partitioning the pixel color layers.

Below the BM layer forming the step portion, a passivation film is formed as an underlying layer and, below the passivation film, at least one of the gate electrode, the gate wiring, the drain electrode, the drain wiring and the source electrode is formed as an underlying layer.

Then, an overcoat layer is formed on the whole surface of the pixel electrode substrate and, after the transparent pixel electrodes are formed, an alignment layer is formed on the whole surface of the pixel electrode substrate. Thus, the slope surfaces, which surround the four sides of each pixel electrode, are formed on the step portion formed by the BM layer.

According to this fabrication method, it is possible to concentrically form the slope surfaces for dividing the orientation of liquid crystal on the side of the pixel electrode substrate during the step of forming the COT structure, while reducing the process load by the use of the COT structure.

According to the present invention, a method for fabricating the orientation dividing type liquid crystal display device, which is featured by that the BM layer is formed on only a portion of the periphery of the pixel electrode and the step portion is formed by partially

overlapping edge portions of adjacent ones of the color filter films during the formation of the pixel color layers corresponding to the pixel electrode and the slope surfaces are formed on the step portion.

5 Furthermore, according to the present invention, an image display method is provided, which uses the orientation division type liquid crystal display device and comprises the step of performing an initial orientation control through the slope surfaces to widen the viewing
10 field of pixel display to thereby clarify the pixel display.

That is, by forming the clearly defined slope surfaces in the peripheries of the four sides of each pixel electrode, liquid crystal molecules on the pixel electrode between the opposing substrate and the pixel electrode
15 substrate become in company with liquid crystal molecules preliminarily oriented vertically to the slope surfaces with an aid of an electric field, which is bulged in an area surrounding the pixel electrode when the orientation direction is changed by applying a voltage across the
20 liquid crystal layer, so that it is possible to immediately determine the alignment direction.

Therefore, it is possible to substantially reduce the response time of initial orientation of liquid crystal molecules within the cell gap and it is possible to evenly
25 divide orientation of liquid crystal molecules on the pixel electrode to a plurality of directions to thereby widen the viewing angle of the pixel display in the pixel region.

BRIEF DESCRIPTION OF THE DRAWINGS

The above mentioned and other objects, features and advantages of the present invention will become more apparent by reference to the following detailed description of the invention taken in conjunction with the accompanying drawings, in which:

FIG. 1 is an enlarged plan view of one pixel electrode portion of a pixel electrode array, conceptually showing an embodiment of an orientation division type liquid crystal display device according to the present invention;

FIG. 2A is a cross section taken along a line A-A in FIG. 1;

FIG. 2B is a cross section taken along a line B-B in FIG. 1;

FIG. 3A is a cross section corresponding to the cross section shown in FIG. 2A, conceptually showing another embodiment of the orientation division type liquid crystal display device according to the present invention;

FIG. 3B is a cross section corresponding to the cross section shown in FIG. 2B, conceptually showing another embodiment of the orientation division type liquid crystal display device according to the present invention;

FIG. 4A is a conceptual cross section of the orientation division type liquid crystal display device, for explaining a size of a cell gap in the present invention;

FIG. 4B is a conceptual cross section of the

orientation division type liquid crystal display device,
for explaining a size relation of a step portion in the
present invention;

FIG's. 5A to 5D are cross sections of the orientation
5 division type liquid crystal display device according to
the present invention, showing a relation between slope
surfaces provided on a substrate surface and orientation of
liquid crystal molecules;

FIG's. 6A to 6D are plan views of typical examples of
10 an electrode opening portion or a protrusion portion
provided in a surface of a transparent electrode surface
(or a common electrode) on the side of an opposing
substrate;

FIG's. 7A and 7B are conceptual cross sections for
15 explaining a relation between a transparent pixel electrode
film (ITO) and a slope surface adjacent thereto; and

FIG's. 8A and 8B show a relation between response time
of division of orientation and height and tilting angle of
the slope portion of the present invention, respectively.

20 DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

FIG. 1 shows one of pixel electrodes 3 of a pixel
electrode array, a TFT (Thin Film Transistor) 100 and a
wiring pattern of an orientation division type liquid
crystal display device according to the present invention
25 and FIG. 2A is a cross section taken along a line A-A in
FIG. 1, showing a drain wiring 10 and the pixel electrode 3
along a direction parallel to a gate electrode wiring 16.

In FIG. 2A, the pixel electrode 3 is provided on the side of a transparent glass substrate (pixel electrode substrate) 1 and a pixel color layer (red) 6R is provided correspondingly to the pixel electrode 3. Although not shown completely in FIG. 2A, a pixel color layer (blue) 6B and a pixel color layer (green) 6G corresponding to the same pixel electrode 3 are arranged on both sides of the pixel color layer 6R.

A black matrix (BM) layer 7 separates the pixel color layers 6R, 6B and 6G from each other and a drain wiring 10 is formed under a passivation film 21 below the BM layer 7. Light shield plates 101 and 201 are formed on outer surfaces of the substrate 1 and an opposing substrate 2 having a common electrode 4.

As shown in FIG. 2B showing a cross section of the pixel electrode 3 taken along a line B-B in FIG. 1, a TFT 100 is formed under the passivation film 21 below the BM layer 7. That is, a gate electrode 20, a gate insulating film 9, a semiconductor 30, a drain electrode 18 and a source electrode 19, etc., are concentrically formed below the BM layer 7, which is formed along the gate wiring 16.

In the cross sectional structure shown in FIG's. 2A and 2B, each pixel electrode 3 on the pixel electrode substrate 1 having the COT structure and each pixel color layer of one pixel color layer region (R, G and B), which is a color filter provided correspondingly to that pixel electrode are related in structure to each other.

In the present invention, the step portion 12 is formed by making the BM layer 7 thick enough and forming an overcoat 11 thereon as an underlying layer of the pixel electrode 3.

5 Particularly, since, in the COT structure, the slope surfaces 13 are formed on the step portions formed by the BM layer, four sides of each pixel electrode are surrounded by the slope surfaces 13. Furthermore, as shown in FIG's. 2A and 2B, alignment layers 5 are formed on an upper
10 surface of the pixel electrode substrate 1 on which the pixel electrodes 3 are formed and a lower surface of the opposing substrate 2 having an upper surface on which the common electrode 4 is formed, respectively.

15 Although the step portions 12 are formed by using the thick BM layer 7 in FIG's. 2A and 2B, such step portions can also be formed by partially overlapping adjacent pixel color layers as shown in FIG's. 3A and 3B. In the example shown in FIG. 3A which is a cross section taken along a line crossing the drain wiring, the adjacent pixel color
20 layers 6R and 6B are partially overlapped on the left side drain wiring 10 to form a step portion 12 and adjacent pixel color layers 6R and 6G are overlapped on the right side drain wiring 10 to form the step portion 12. In the example shown in FIG. 3B which is a cross section taken
25 along a line crossing a gate wiring 16, the step portion 12 is formed by partially overlapping adjacent color layers on the gate wiring 10.

As mentioned above, the liquid crystal display device according to the present invention includes a pixel color layer region (R, G and B) as a color filter for each pixel electrode and is suitably used as an active matrix drive, orientation-division type liquid crystal display device
5 having the COT structure in which the slope surfaces are formed on the side of the pixel electrode substrate.

The present invention is featured by that the slope surfaces provides two cell gaps. There is a preferable
10 range of a ratio of one cell gap to the other cell gap.

Assuming that a gap between portions of the pixel electrode substrate 1 and the common electrode substrate 2, which oppose each other in an area of the step portion 12, is referred to as a first cell gap G_1 and a gap between
15 portions of the substrates 1 and 2, which oppose each other in an area of the pixel electrode 3, is referred to as a second cell gap G_2 as shown in FIG. 4A, the gap ratio G_1/G_2 is preferably in a range from 2/10 to 9/10.

When the gap ratio G_1/G_2 is sufficiently smaller than
20 2/10, liquid crystal molecules are tilted too much and become substantially parallel to the surface of the pixel electrode, resulting in that orientation of liquid crystal molecules is hardly divided effectively. On the contrary, when the gap ratio G_1/G_2 is sufficiently larger than 9/10
25 and, in order to make an angle of the slope surface to a desired value, a length of the slope surface becomes too long, resulting in that the aperture ration of the pixel

electrode surface tends to be reduced unfavorably. A more preferable range of the gap ratio is from 3/10 to 8/10.

Thus, when the slope surfaces are provided on the pixel electrode substrate of the liquid crystal display device having the COT structure and a voltage is applied across the cell gap, a resulting electric field is bulged in a slope surface direction of the peripheral portions of the pixel electrode surface as shown in FIG. 5A and liquid crystal molecules in the first gap on the surface of the pixel electrode are oriented along the bulged electric field, so that liquid crystal molecules on the pixel electrode are differently oriented, resulting in a divided orientation. Furthermore, the viewing angle of the pixel display is widened.

Moreover, in the present invention, the slope surfaces are provided on the pixel electrode substrate and, on demand, an electrode opening 4a is provided in the common electrode 4 on the side of the opposing substrate 2 corresponding to the pixel electrode, as shown in FIG. 5B.

For example, by providing the opening 4a in the common electrode corresponding to a center portion of the pixel electrode, the electric field in that portion is bulged along a wall of the opening, so that liquid crystal molecules are oriented along a bulged plane. Thus, it is possible to further improve the divided orientation, as shown in FIG. 5B.

Alternatively, it is possible, in order to obtain a

similar effect, to form a downward protrusion 4b having slope surfaces on the lower surface of the common electrode instead of the opening 4a, as shown in FIG. 5C. If the step portions were provided on the side of not the pixel

5 electrode substrate but the opposing substrate 2 as shown in FIG. 5D, the initial orientation of the liquid crystal molecules on the side of the opposing substrate 2 should become opposite to that on the side of the pixel electrode substrate 1 as shown by arrows, so that it is impossible to
10 divide the orientation of liquid crystal molecules to a plurality of domains uniformly.

FIG's. 6A and 6B are plan views of an X-shaped opening portion 141 and a modified X-shaped opening portion 142 as examples of the opening portion, which are formed in the
15 common electrodes 4 correspondingly to a shape of the pixel electrodes, respectively.

Furthermore, FIG's. 6C and 6D are plan views of an X-shaped protrusion 151 and a modified X-shaped protrusion 152 as examples of the protrusion formed on the common
20 electrode 4.

In forming the pixel electrode, it is preferable that peripheral portion of the transparent pixel electrode film 3 is not overlapped on the slope surfaces 13 as shown in FIG. 7A. More preferably, a gap d_1 at the edge portions of
25 the pixel electrode 3 becomes substantially the same as the gap d_0 at the center portion thereof as shown in FIG. 7B.

That is, in FIG's. 7A and 7B, a relation between

transmitting light intensity I of the liquid crystal layer and the gap d of the liquid crystal layer, that is, thickness of the liquid crystal layer, satisfies the following equation:

5
$$I = I_0 \sin^2 2\theta \sin^2 (\pi dn/\lambda)$$

where I_0 is an intensity of incident light, θ is an angle between a direction of incident polarized light and a vibration direction of usual light in a cell, n is a birefringence rate at applied voltage V and λ is light
10 wavelength.

As is clear from the above equation, transmitted light intensity I is proportional to the gap d . Therefore, if the peripheral portion of the transparent electrode 3 is overlapped on the slope surface as shown in FIG. 7A, the
15 gap d_2 on the edge portion of the electrode 3 becomes smaller than the gap d_0 in the center portion thereof ($d_2 < d_0$), so that light transmittivity of the peripheral portion of the pixel electrode is reduced, causing brightness of the pixel display to be uneven.

20 In the present invention, the slope surfaces are provided such that liquid crystal molecules on the pixel electrode are oriented vertically with respect to the slope surfaces. Therefore, it is preferable that the alignment
layers 5 shown in FIG's. 2A and 2B are vertical alignment
25 layers so that liquid crystal molecules 8 are oriented vertically with respect to the surface of the pixel electrode substrate.

In addition to the use of the vertical alignment layers, liquid crystal filling the gap between the substrates is preferably liquid crystal having a negative dielectric anisotropy.

5 From the above, a method for fabricating the orientation division type liquid crystal display device having the step portions on the pixel electrode substrate having the COT structure and the slope surfaces formed on the step portions according to an embodiment of the present
10 invention will be described with reference to FIG's. 2A and 2B.

In FIG. 2B, after a conductive film of Cr, etc., is formed on the transparent substrate 1 formed of, for example, a glass material, the gate electrode 20 and the
15 gate wiring shown in FIG. 2B are formed by patterning the conductive film with using a predetermined mask related to the pixel electrode array. Thereafter, the gate insulating film 9 of such as silicon nitride is formed on the wafer to cover the gate electrode and, then, the semiconductor layer
20 30 of amorphous silicon is formed on the gate insulating film 9. The semiconductor layer 30 is then subjected to photolithography process to provide a predetermined patterning.

Thereafter, the drain electrode 18, the drain wiring
25 10 (FIG. 2A), the source electrode 19 and the source wiring are formed of a conductive material such as molybdenum through similar patterning processes. Then, the passivation

film 21 of an insulating material such as silicon nitride is formed on the wafer.

Thereafter, the color layers 6, which become the color filter, are formed. The color layers 6 are usually resin films containing red (R), green (G) and blue (B) dyes or pigments, respectively. The color layers 6 are formed by forming the red layer 6R, the green layer 6G and the blue layer 6B. Each of the red, green and blue layers is formed through the steps of, for example, painting the wafer with a resist film in the form of a negative type light sensitive resin film containing acrylic resin as a base material and one of the red, green and blue pigments dispersed therein, with using the spin coating, pre-baking the resist film, patterning the resist by exposition and development with using a photo mask and, finally, post-baking it.

Then, as shown in FIG's. 2A and 2B, the BM layer 7 is formed as the light shield film. The BM layer 7 is formed through similar steps to those used to form the color layer 6 except that black pigment is dispersed in the acrylic resin.

Thereafter, the overcoat layer 22 of thermosetting resin such as acrylic resin, which is a transparent insulating layer, is formed on the BM layer 7 and, then, a contact hole 17 is formed in a predetermined position on the source electrode 19, as shown in FIG. 2B.

Then, the pixel electrode 3 in the form of a

transparent conductive film such as an ITO film is formed through the patterning step including the steps of sputtering, photolithography and etching. In this stage, the pixel electrode 3 is connected to the source electrode 19 through the contact hole 17, as shown in FIG. 2B. Furthermore, as shown in FIG's. 2A and 2B, the alignment layer 5 is formed on the uppermost layer of the wafer as a polyimide film, a polyvinyl film or a slant vapor-deposited SiO film.

10 In the present invention, the step portion 12 can be easily formed by setting the thickness of the BM layer such that an upper surface of the BM layer becomes higher than the surface of the color layer 6, as shown in FIG's. 2A and 2B.

15 In the present invention, the overcoat layer 22 and the alignment layer 5 are formed on the step portion 12 thus formed by the BM layer 7 such that the cross section of the lamination of the alignment layer 5, the overcoat layer 22 and the step portion 12 becomes trapezoidal as shown in FIG's. 2A and 2B. Root portions of the slope surfaces of the step portions on the opposite sides of the pixel electrode are in the vicinity of the opposite peripheral portions of the pixel electrode. As a result, the slope surfaces rise from the opposite side edge portions of the pixel electrode.

Assuming that height H of the slope portion is defined by a distance between an uppermost surface of the alignment

layer on the step portion having the trapezoidal cross section and the surface of the alignment layer on the pixel electrode and length L of the slope portion is defined by a distance in the width direction of the step portion between the above mentioned side edge portion and an edge of the uppermost surface of the alignment layer on the step portion, as shown in FIG. 4B, the length L is preferably equal to a length in a horizontal plane of the substrate between a position on the slope surface of the step portion, which is about 20% of the height H, and the edge of the uppermost surface of the alignment layer.

When the position on the slope surface of the step portion is lower than 20% of the height H, the material of the alignment layer in liquid state tends to be pooled in the root portion of the slope portion during the formation of the alignment layer, so that it is difficult to control the length of the slope surface.

As mentioned previously, it is possible in the present invention to set the height of the slope portion through this step portion suitably by regulating the thickness of the BM layer.

Furthermore, the length L of the slope surface in the width direction of the step portion can be suitably regulated by regulating an exposing time when the BM layer is patterned.

Moreover, the height H and the length L of the step portion can be suitably regulated by regulating the

thickness of the overcoat layer.

For example, when the height H of the slope portion is 1.1 μm and the length L of the slope surface is 2.0 μm , the thickness of the BM layer is 1.3 μm and the thickness of
5 the overcoat layer is 0.4 μm .

The present invention is featured by that the clearly defined step portion is formed in the side edge portions of the pixel electrode corresponding to the pixel color layer by forming the BM layer as thick as 1.3 μm between the
10 adjacent pixel color layers.

As mentioned previously, the BM layer is formed by forming the pigment dispersed resist by using a coating process such as spin coating.

When the BM layer as thick as 1.3 μm is formed by
15 etching a silicon nitride or silicon oxide film, it is necessary to form a plurality of silicon nitride or silicon oxide films since thickness of such film, which can be formed in one time, is usually in a range from several nm to several tens nm. Therefore, the spin coating used in the
20 present invention can substantially reduce the process load compared with the etching method.

Through the above mentioned fabrication method according to the present invention, the first cell gap G_1 and the second cell gap G_2 are provided with the gap ratio
25 $(G_1/G_2) = 2/10 \sim 9/10$, as mentioned previously.

Furthermore, for the above mentioned reason, the transparent electrode film of the pixel electrode can be

suitably formed such that the transparent electrode film is not overlapped with the slope surfaces.

In order to orient liquid crystal molecules vertically with respect to the slope surfaces, the alignment layers
5 formed on the pixel electrodes and the slope surfaces of the pixel electrode substrate and on the common electrode substrate are preferably formed as the vertical alignment layers.

As shown in FIG's. 6A to 6D, the suitably patterned
10 electrode opening portion is formed in the common electrode of the common electrode substrate, that is, the opposing substrate, or the suitably patterned protrusion is formed on the lower surface of the common electrode, on demand, and the opening or the protrusion can be formed by using
15 any known method. Other structural elements are formed on the side of the pixel electrode substrate concentrically.

Advantages of the present invention are described with reference to the preferred embodiments. It should be noted, however, that the present invention is not limited thereto.

20 (Embodiment 1)

Four liquid crystal cells having the COT structures including step portions having slope length L of $2.0\text{ }\mu\text{m}$ commonly and heights H of $0.4\text{ }\mu\text{m}$, $0.8\text{ }\mu\text{m}$, $1.1\text{ }\mu\text{m}$ and $1.8\text{ }\mu\text{m}$, respectively, were prepared and response times of the
25 respective liquid crystal cells were measured while applying voltages in a range from 0 V to 5 V across the liquid crystal cells. Table 1 and FIG. 8A show the result

of the measurement. Incidentally, the thickness of the liquid crystal layers, that is, the second cell gaps G_2 , were 4.0 μm , commonly.

5

<Table 1>

| | | | | | |
|--------------------------------|----------|------|------|------|------|
| slope height (μm) | no slope | 0.4 | 0.8 | 1.2 | 1.8 |
| height ratio (%) | - | 10 | 20 | 28 | 45 |
| response time (ms) | 272.9 | 62.1 | 31.9 | 20.6 | 15.7 |

10

The height ratio in Table 1 is a ratio (%) of the height of the slope to the thickness of the liquid crystal layer.

15

As is clear from Table 1, the response time is substantially improved by the provision of the slope formed on the step portion. When the slope height is 0.8 μm , the response time becomes about a half of that obtained when the slope height is 0.4 μm and is further improved with increase of the slope height.

20

From this result of the measurement, it is preferable that the height ratio of the slope with respect to the thickness of the liquid crystal layer is 20 % or more, more preferably, 28 % or more.

25

The height of the slope portion of 0.4 μm corresponds to the usual thickness of the gate insulating film of silicon nitride or silicon oxide when the gate insulating film is formed.

According to the present invention, the response time

is further reduced by increasing the thickness of the gate insulating film to, for example, 0.8 μm .

In addition, since it is easy to regulate the height of the slope by means of an organic resist used for the formation of the BM layer, the forming process thereof is substantially simplified compared with a case where the slope portion is formed by piling a plurality of silicon nitride films. Therefore, the formation of the slope portion according to the present invention is very preferable in view of advantages of the simplified process with shortened time and the uniformity of the formed slope portion, etc.

(Embodiment 2)

Four liquid crystal cells having the COT structures, which are similar to those in the embodiment 1 and include step portions having slope heights H of 1.1 μm commonly and slope lengths L of 1.2 μm , 2.0 μm , 3.5 μm and 5.8 μm , respectively, were prepared and response times of the respective liquid crystal cells were measured while applying voltages in a similar range to that used in the embodiment 1 across the liquid crystal cells. Table 2 and FIG. 8B show the result of the measurement. Incidentally, the thickness' of the liquid crystal layers, that is, the second cell gaps G_2 , were 4.0 μm , commonly, and the tilting angle θ of the slope is represented by the following equation:

$$\theta = \tan^{-1} (H/L)$$

<Table 2>

| | | | | | | |
|---|--------------------------------|----------|------|------|------|------|
| | slope length (μm) | no slope | 1.2 | 2.0 | 3.5 | 5.8 |
| | tilting angle (θ) | - | 43 | 29 | 17 | 11 |
| 5 | response time (ms) | 272.9 | 18.1 | 20.6 | 31.0 | 48.2 |

As is clear from Table 2, the response time to the orientation division of the liquid crystal layer is substantially improved by the provision of the slope formed on the step portion.

That is, it is clear that the response time is improved by setting the slope length L to a value smaller than $5.8 \mu\text{m}$ to increase the tilting angle of the slope. Particularly, when the slope length L is smaller than $2.0 \mu\text{m}$, the response time is further reduced. Therefore, it is clear that the response time of the liquid crystal orientation division is further improved by using the tilting angle of the slope larger than 11° , preferably, larger than 29° .

Table 3 shows a relation between G_1/G_2 ratio and H/G_2 ratio, with which the aperture ratio of a pixel electrode, which has an area $300 \mu\text{m} \times 100 \mu\text{m}$, the first cell gap $G_1 = 4 \mu\text{m}$ and the tilting angle of the slope of 11° , 50 % or more.

<Table 3>

| | | | | |
|-----------------|--------|--------|--------|------|
| G_1/G_2 ratio | 7.2/10 | 6.5/10 | 2.0/10 | 0/10 |
|-----------------|--------|--------|--------|------|

| | | | | |
|-------------------------------|--------|--------|--------|-------|
| H/G ₂ ratio | 2.8/10 | 3.5/10 | 8.0/10 | 10/10 |
| aperture ratio (≥ 50 %) | ○ | ○ | ○ | × |

According to the present invention, it is possible to
5 uniformly divide orientation of liquid crystal filling the
gap between the pixel electrodes on the pixel electrode
substrate having the COT structure and the common electrode
of the opposing substrates to a plurality of orientations
by providing the slopes surrounding the respective pixel
10 electrodes.

Furthermore, it is possible to substantially reduce
the initial orientation response time required to uniformly
align liquid crystal molecules and divide the direction of
alignment to a plurality of directions when a voltage is
15 applied to the liquid crystal cells in order to drive the
liquid crystal cells.

Therefore, according to the present invention, it is
possible to provide an orientation division type liquid
crystal display device, which has the COT structure and the
20 slopes surrounding the respective pixel electrodes and is
capable of aligning and dividing the orientation of liquid
crystal molecules to a plurality of orientations in the
initial orientation within a shortened response time to
thereby increase the viewing angle of the pixel display by
25 the pixel electrodes, an image display method and a
fabrication method of the display device.